## SILTERRA







# Ibero-America IC Design Contest (Silterra, Chipus & ISTEC)

Florida International University - April 25, 2013

**Foundry Partnership For Success** 





#### **2013 IC Design Contest**



#### **Background:**

The IC Design Contest is a collaboration between Silterra Malaysia, a leading Malaysian foundry, Chipus Microelectronics, a Brazilian analog IP design house, and the Ibero-American Science&Technology Consortium, ISTEC.

The goals of this contest are:

- For Silterra, as an ISTEC partner, to help foster research and innovation in Ibero-America
- To introduce Silterra as a foundry of choice for Latin-American IC designers
- To allow designers in the region to have their designs validated in silicon

#### **Details:**

- ➤ The contest will be open to university, R&D Institutes and R&D company departments, with access to EDA tools compatible with Silterra PDKs
- > The designs to be based on Silterra's 0.18 micron technology
- Details about design categories will be disclosed soon







#### **2013 IC Design Contest**



#### Details (cont.):

- Contest to run throughout 2013
- ➤ The best design in each category will be chosen by using a figure-of-merit (FOM) to be announced later
- Access to Silterra's PDKs/technology specs to be provided to the contestants
- ➤ The winner design in each category will be offered a free shuttle in a Silterra MPW for silicon verification

Preliminary information is provided at the contest website:

www.icdesigncontest.com

Further details on the IC design contest to be updated on the contest website.



#### **SilTerra Overview**

## SilTerra headquarters located at Kulim Hi-Tech Industrial Park, Malaysia

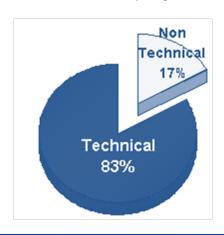
- Worldwide reachable Sales offices in the U.S. and Taiwan
- Business Partners in China, Japan, Korea & Europe

#### Production started in Q1 2001

- Top Fab of 2002 (Semiconductor International)
- ISO 9001:2008, ISO 14001:2004, OHSAS 18001:2007 and QC 080000 certified

#### Workforce Competency

>1200 employees







#### **Our Core Business**

Offer Foundry Solutions for Advanced CMOS & Specialty Technologies

- Leading foundry-matched logic technologies (T-like & U-like)
- Mixed-signal and RF technologies
- Leading-edge high voltage technologies
- Advanced Analog technologies (BCD, V-Tr FET)
- MEMS
- Non-Volatile Memory (OTP, MTP and eFlash)

" More
Than
Moore"
Tech



### SilTerra's Focused Strategies

#### **Provide Leading Foundry Matched Processes**

- Logic, mixed signal and RF
- High voltage technologies for display drivers
- BCD/PowerMOS technologies for Smart Power IC
- Embedded NVM tech for consumer applications

### Offer Specialized Technologies

 Custom processes to meet special requirements



### Deliver World-class Manufacturing Performance

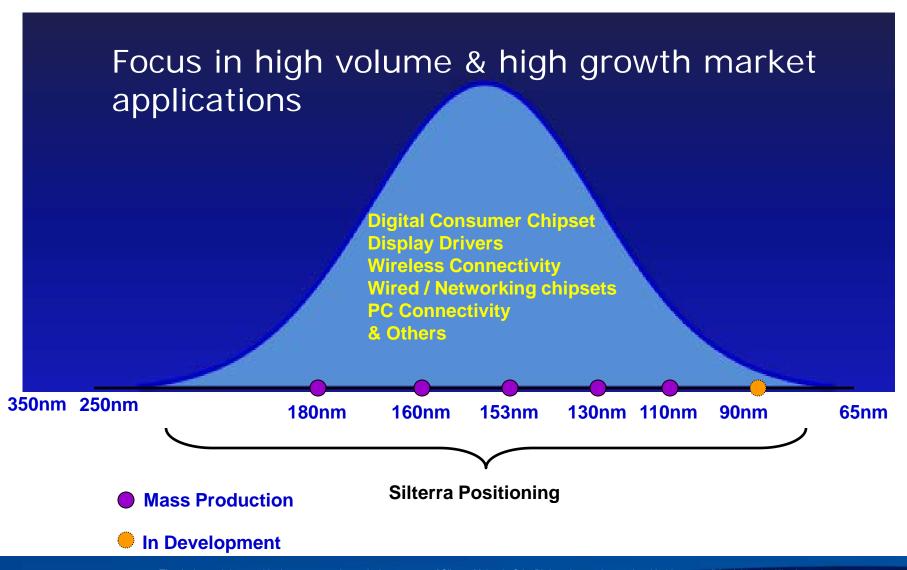
- First time proto success
- 6 Sigma QC program for continuous improvement in yield, cycle-time & cost reduction,

#### Leverage IP and Design Network for Complete Design Solution

- Application driven IP strategy
- Best-in-class IP blocks



#### SilTerra Market Positioning





### **Our Target Market**



**Mobile TV Tuner** 

WLAN / GPS

**RF Transceiver** 

**Bluetooth Link** 

**FM Tuner** 

**GPS** 

#### Comms



**Printer Fax Modem** 

Router (xDSL)

**Switches** 

**Home Gateway** 

**USB Modem** 

#### Computing





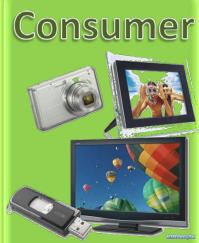
**PCIe-SATA Bridge** 

**PCIe-USB Bridge** 

**SSD Controller** 

**ROM/RW Drive** 

**PC Audio** 



**Display Driver** 

**Touch Controller** 

**DTV T-Con** 

**SD Memory Controller** 

**Digital Photo Frame** 

**USB Flash Drive** 

MP3 / PMP



### Logic Technology Leadership

- Leading foundry compatible processes
- High volume production with stable yield
- Intercept sweet spots of target application segments
- Offer cost effective migration path (0.18µm to 0.11µm)
- Offer 130nm and 110nm Aluminum BEOL
- Provide high quality design kits
- Supply application optimized IP blocks











### RF CMOS Technology Leadership

- Advanced RF CMOS technologies
  - High performance, low noise processes
  - Triple-well, high value resistors, thick metal inductors, finger and MiM caps
  - Stacked MiM Caps (4fF/µm²)
  - Redistribution Layers
  - Offered 0.18, 0.16, 0.13μm & 0.11μm RFCMOS nodes
  - 0.13 & 0.11 RFCMOS Al BEOL in development
- Accurate analog models
  - MOSFET characterized to 20GHz
  - Support BSIM3, BSIM4 & PSP Models
- Comprehensive PDK















### High Voltage Technology Leadership

- Advanced processes optimized for display drivers
  - 0.22μm to 0.11μm
  - Extremely low leakage
  - Industry leading aggressive SRAM cells (25% smaller) for high resolution displays
  - Three HV modules available: 6V, 21V and 32V
- Industry first C13HV-1TSRAM in production
- Winner of 2009 Frost and Sullivan Industrial Technologies Award
- High volume production for top tier customers
- Customized design libraries
- OTP Macro & eFuse bitcell are available
- MTP and 90nm HV is in development







### **POWER MOSFET Value Propositions**

- 0.18µm Power MOSFET Technology
- Trench-type Gate electrode
- Low Rdson MOSFET devices (20V, 30V, 60V and 75V Vbd)
- Low mask count
- Superb yield and device performance
- Target for DC-DC Converter socket in Battery charger and Notebook
- Design Service supported



#### 180nm BCDMOS Value Propositions

- Integrated with 0.18um logic CMOS 1.8/5V with HV LDMOS (20V/24V/40V). 50V/60V in development
- Optimized for applications requiring high voltage CMOS with high digital gate counts with thick metal.
- Integrated with SilTerra 0.18um RFCMOS processing capability for complete power equipped wireless SoC.
- Skillful resurf technique allows wide range of breakdown voltage to be obtained thru layout optimization for HV transistors.
- TCAD calibrated for HV LDMOS allows Pre-defined HV LDMOS with various on-resistances optimized for BVDss and area.
- Analog and passive options (MiM, HRI, UTM, NPN/PNP, Zener, SBD) fasten the design.
- Cadence proven foundry design kit.

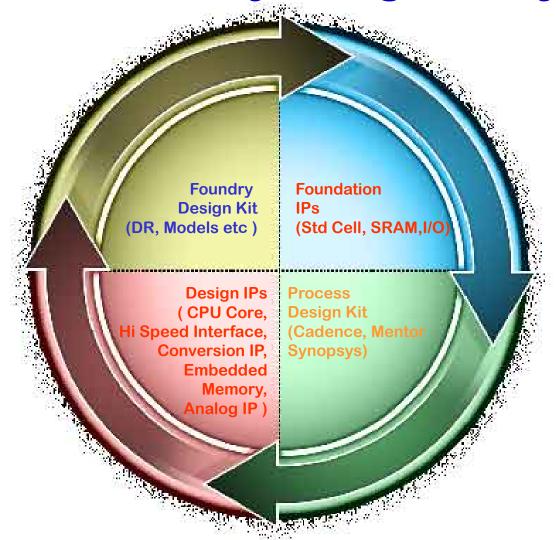


#### Platform-Based IP Strategy

- Best-of-breed application focused IP portfolio
  - Analog blocks, high speed I/Os, processor cores, memories
  - Foundation design libraries
- Silicon proven IP blocks
  - Enable fast design cycles and first-time-success
- Extensive partnership network to provide IP and design support
  - Custom IP to meet specific design requirements
  - Fast turn-around time

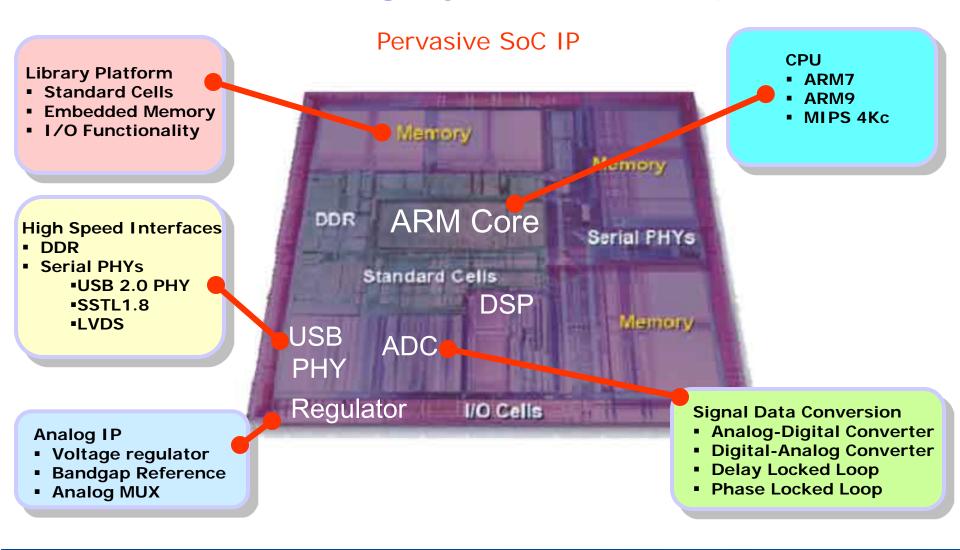


#### Complete Foundry Design Ecosystem





#### **Enabling System on Chip**





### **Non-Volatile Memory Solutions**

Partner

Tech

**Applications** 





All Logic All HV

**ROM Code Fuse Trim** Gamma Control **Analog Matching** 







SYNOPSYS C18G/C16G C13HV/C11HV

**RFID Touch Controller** 



eFlash

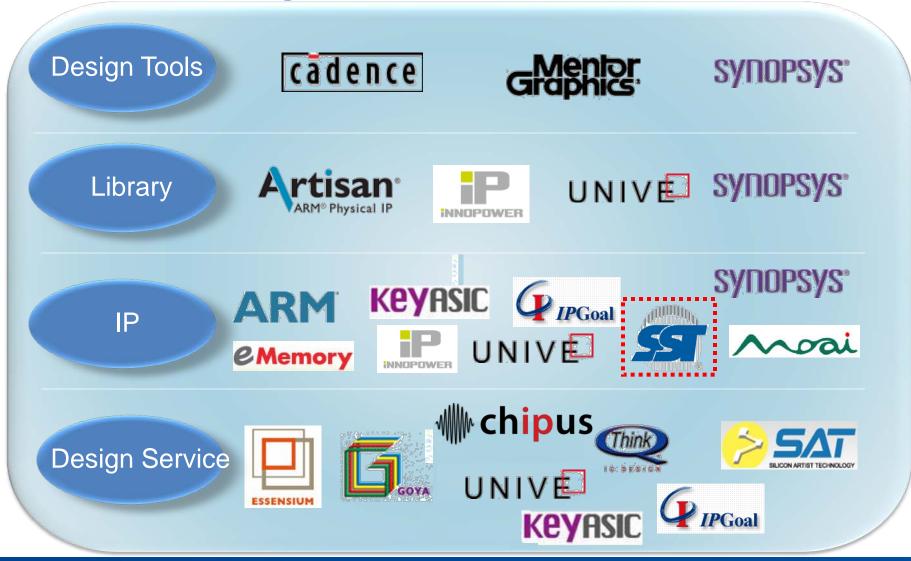


C18G

Smart Card **MCU** 



#### **Design Solutions Partners**





#### Fab 1 Overview

Wafer size: 200mm

Equipment is capable down to 90nm

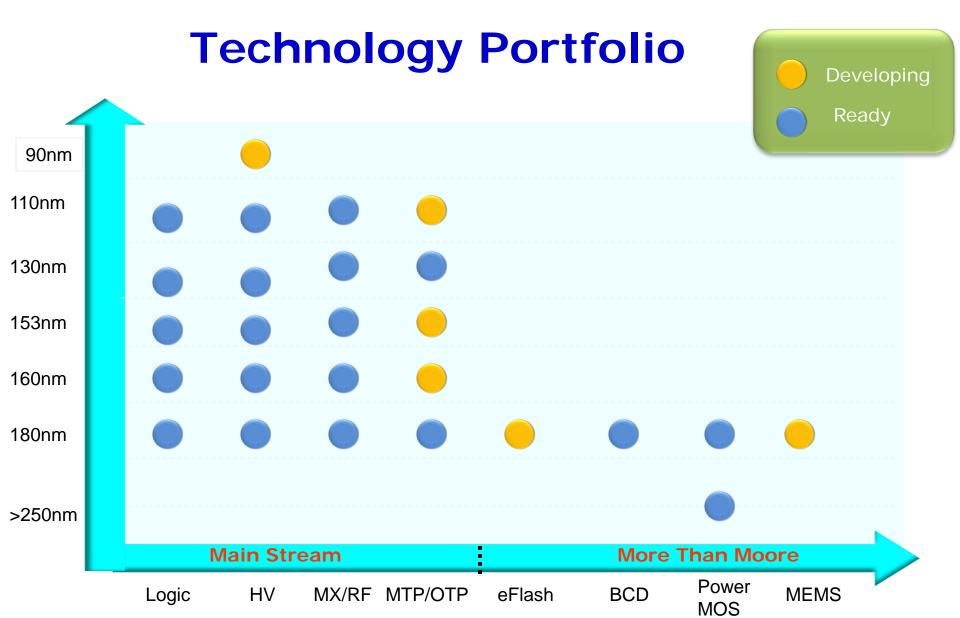
Designed capacity: 40,000 WSPM

Installed capacity: 38,000 WSPM

 100,000 feet<sup>2</sup> Class 100 clean room SMIF Class 1 mini-environments

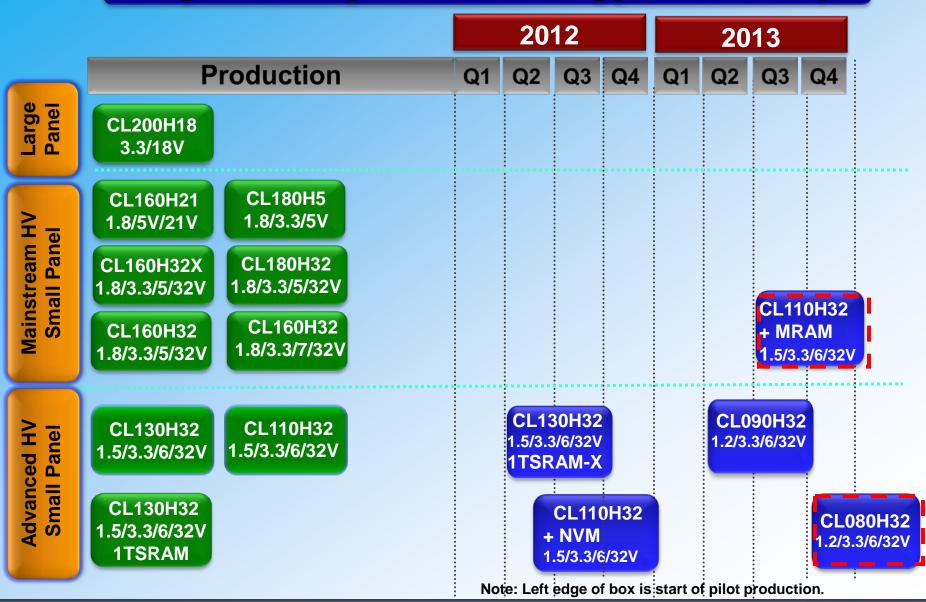
- 100% ASML scanners (I-Line, DUV & ArF)
- ISO 9001: 2008, ISO 14001: 2004, OHSAS 18001: 2007 and QC 080000 certified







### High Voltage Technology Roadmap





#### Logic, LP & Mixed Signal Technology Roadmap

2013 2012 **Production** Q2 Q3 **Q4 Q1** Q2 Q3 **Q4 Q1 CL090G CL110U CL130U CL130G CL110G** 1.0/1.8, 2.5, 1.2 / 3.3V 1.2 / 3.3V 1.2/2.5, 3.3V 1.2/2.5, 3.3V 3.3V CL130Mix VT CL130LVT CL130HVT **CL110G5** 1.2/2.5, 3.3V 1.2/2.5, 3.3V 1.2/2.5, 3.3V 1.2 / 5V **CL180GH5 CL160GH5 CL180G5 CL130GH5 CL130G5** 1.8/5.0V 1.8/5.0V 1.8/5.0V 1.2 / 5V 1.2 / 5V **CL180G CL160G CL153G** CL110AL CL130AL 1.8/3.3V 1.8/3.3V 1.8/3.3V 1.2/3.3V 1.2 / 3.3V **CL110GH5** 1.2/5.0V CL090LP CL180LP CL130LP 1.2/1.8, 1.8/3.3V 1.5/2.5, 3.3V 2.5, 3.3V Note: Left edge of box is start of pilot production CL130MixVT is the combination of C13G and C13HVT.



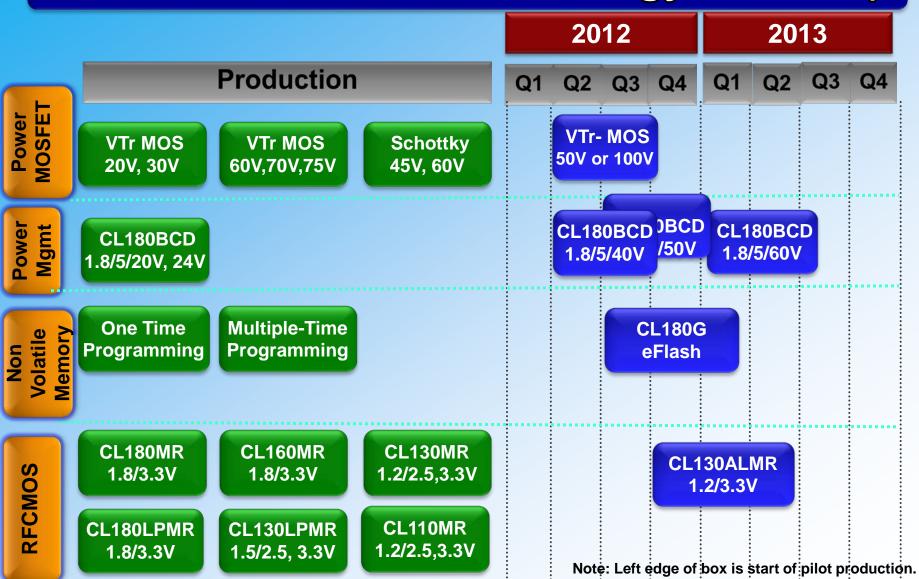
Power

Signal

Mixed

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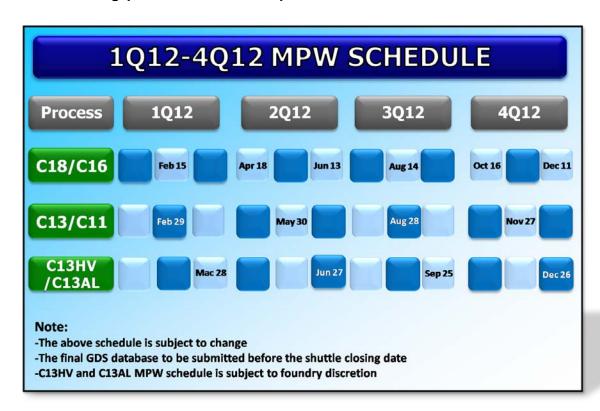
#### "More Than Moore" Technology Roadmap

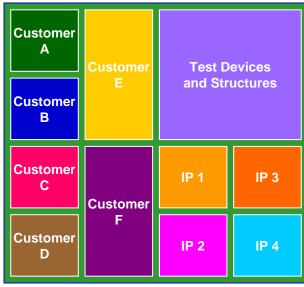




#### Silicon Verification Vehicle

- Multi-project design and IP verification service
- Typical test chip size (5mm x 5mm )









### Why SilTerra?

- Proven Leading Foundry Matched Process
- Leader in HV CMOS Technology
- Complete Foundry Design Ecosystem
- First Time Proto Success
- High Yielding Wafers
- Cost Competitiveness
- Turnkey Service (Design to Backend)

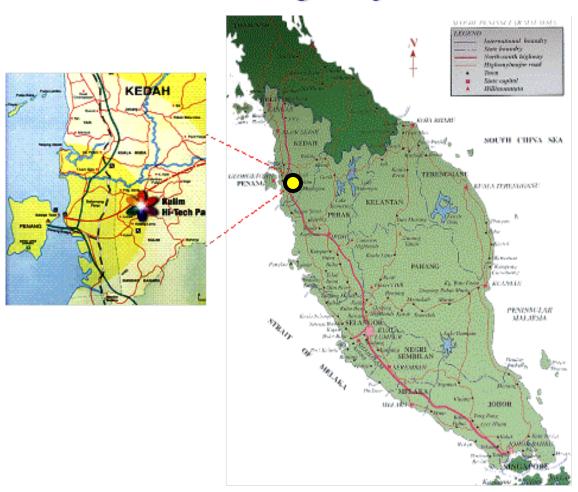


#### **Contact Information** SILTERRA **Corporate HQ KL Office** Kulim Hi-Tech Park **Bandar Utama** Malaysia Malaysia T: 604.401.5111 T: 603.7726.6610 **U.S. Office Taiwan Office** San Jose, CA. HsinChu City USA Taiwan T: 1.408.530.0888 T: 886.3.516.5577



#### **Corporate Location**

## Corporate headquarters and manufacturing facility are strategically located in KHTP, Malaysia.



#### Kulim High Tech Park

- 30km from Penang
- No typhoons and geologically stable
- Access to highly educated technical labor force
- Current tenants include Intel, First Solar, BASF Infineon, Celestica, Fuji Electric, Hoya, MEMC, Toyo Memory, Asyst, Novellus and others
- High quality infrastructure
  - Reliable power supply
  - Malaysian Cybercity status
  - High capacity fiber optic network
  - Abundant water supply from 3 dedicated reservoirs

